

1st international workshop



SPEM2010

Present and Future of the ScanningPhotoElectron Microscopy: bridging the pressure gap

Trieste, Italy 13-14 December 2010

SPEM2010 is the 1st forum bringing together experts in ScanningPhotoElectron Microscopy and Ambient Pressure XPS to discuss the present status and directions for merging both techniques. The scope is to disseminate the capabilities of the instruments to a broad audience of the academic and industrial communities and highlight the most recent achievements in research and instrumental development. Topics will cover the current status of the operating SPEMs and new SPEMs under construction, new approaches and future developments with emphasis on the solutions bridging the pressure gap in SPEM.

